

WELCOME TO THE COURSE

ON

MICRO MACHINING PROCESSES

BY



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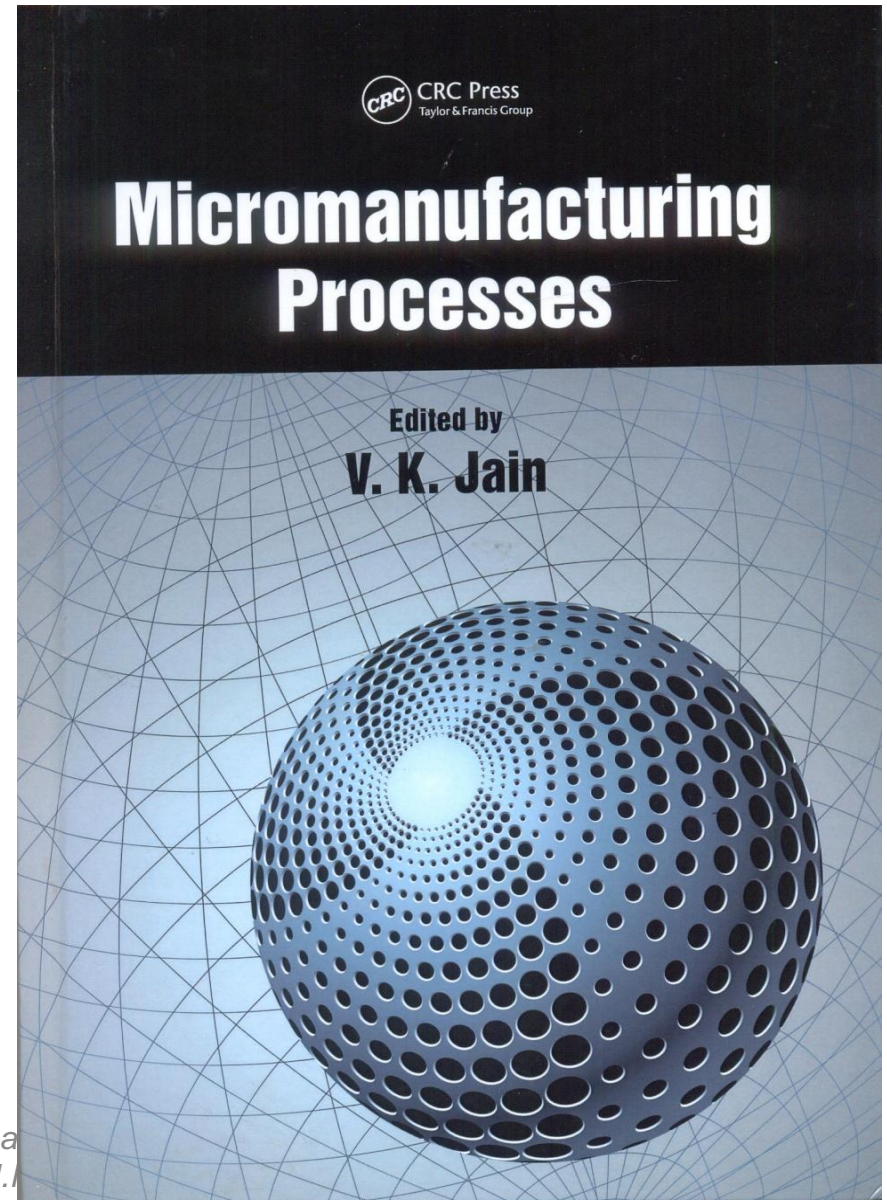
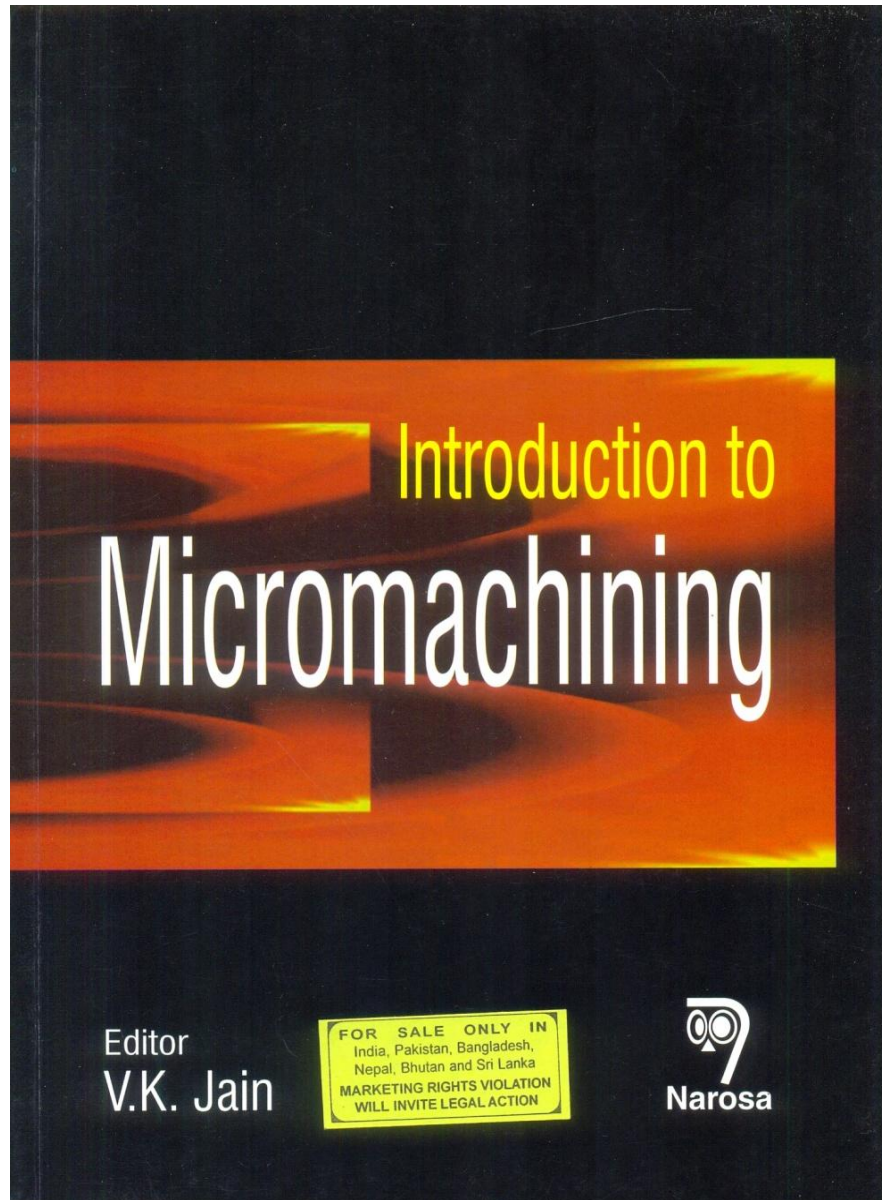
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ORGANISATION

- TEXT BOOKS
- CHAPTERS TO BE COVERED IN THIS COURSE ON “MMPs”
- WHY DO YOU NEED MMPs
- CLASSIFICATION OF MMPs
- EVOLUTION AND WORKING PRINCIPLES OF SOME AMPs
- APPLICATIONS OF MMPs
- CONCLUSIONS

ADVANCED MACHINING PROCESSES



Grading Policy

Mid Sem. Exam--> 30 %

End Sem. Exam → 40 %

Term Paper → 15%

Lab. Visits → 05%

Attendance → 05%

Quizzes (unannounced)-- → 05%

For getting “D” or better grade, one should have minimum 30 % marks in both theory exams (Mid Sem. + End Sem.) and 35 % in total. For getting ‘E’ , One should have 25 % in theory and 30 % in total.

TEXT BOOKS

BOOKS

- ❖ ***INTRODUCTION TO MICROMACHINING*, V.K.JAIN (EDITOR) PUBLISHED BY NAROSA PUBLISHERS, NEW DELHI (2009). (second Edition)**
- ❖ **MICROMANUFACTURING PROCESSES BY V. K. JAIN (Editor), CRC PRESS.**
- ❖ ***ADVANCED MACHINING PROCESSES* BY V.K JAIN , ALLIED PUBLISHERS, NEW DELHI.**
- ❖ ***NON- CONVENTIONAL MATERIAL REMOVAL PROCESSES* BY V.K.JAIN, BLOCK-4, INDIRA GANDHI NATIONAL OPEN UNIVERSITY (IGNOU), NEW DELHI**

Reference Books

- ❖ **MICROMACHINING METHODS BY J.A. Mc GEOUGH, CHAMPAN AND HALL, LONDON**

TOPICSTO BE COVERED

SUBJECT AREAS

S.N	TOPIC
1	INTRODUCTION TO THE COURSE & CLASSIFICATION OF MMPs
PART – 1 : MECHANICAL TYPE ADVANCED MICRO MACHINING PROCESSES	
2	ABRASIVE JET MICRO MACHINING (AJMM)
3	ULTRASONIC MICRO MACHINING (USMM)
4	ABRASIVE WATER JET MICRO MACHINING (AWJMM)
PART – 2 : ABRASIVE BASED NANO FINISHING PROCESSES	
5	ABRASIVE FLOW FINISHING (AFF)
6	CHEMOMECHANICAL POLISHING (CMP)

SUBJECT AREAS

S.N	TOPIC
7	MAGNETIC ABRASIVE FINISHING (MAF)
8	MAGNETORHEOLOGICAL FINISHING (MRF)
9	MAGNETORHEOLOGICAL ABRASIVE FLOW FINISHING (MRAFF)
10	MAGNETIC FLOAT POLISHING (MFP)
PART – 3 : THERMOELECTRIC TYPE MICRO MACHINING PROCESSES	
11	ELECTRIC DISCHARGE MICROMACHINING (EDMM)
12	WIRE EDM , EDDG, ELID
13	LASER BEAM MICROMACHINING (LBMM)
14	ELECTRON BEAM MICROMACHINING (EBMM)

SUBJECT AREAS

S.N	TOPIC
PART – 4 : CHEMICAL AND ELECTROCHEMICAL TYPE ADVANCED MACHINING PROCESSES	
15	ELECTROCHEMICAL MICROMACHINING (ECMM)
16	ELECTROCHEMICAL MICRO DEBURRING
17	CHEMICAL AND PHOTOCHEMICAL MICROMACHINING
PART-5 : TRADITIONAL MECHANICAL MICROMACHINING PROCESSES	
18	MICRO TURNING
19	MICRO MILLING

SUBJECT AREAS

S.N	TOPIC
20	MICRO DRILLING
PART- 6 : MISCELLANEOUS TOPICS	
21	FOCUSSED ION BEAM (FIB) MACHINING
22	SELECTION OF MICRO MACHINING PROCESSES
23	CONCLUDING REMARKS

INTRODUCTION

- In today's high tech engineering industries, the designer's requirement for the component are stringent, such as:
 - **Extraordinary properties of materials** (say, high Strength, high heat resistant, high hardness, corrosion resistant etc.).
 - **Complex 3D component** (say, turbine blade).
 - **Miniature features** (filters for food processing and textile industries having a few tens of micrometer as hole diameter and thousands in numbers).
 - **Nano level surface finish on complex geometries which are impossible to achieve by any traditional methods** (say , thousands of turbulated cooling holes in a turbine blade, making & finishing of microfluidic channels in the electrically conducting and non-conducting materials (say, glass, quartz, ceramics)).
- Such features on a component can be achieved only through the **advanced manufacturing processes** in general and **advanced machining processes** in particular.

PRESENT DAY DEMAND TRENDS IN INDUSTRIES (AEROSPACE , MISSILES , AUTOMOBILES, NUCLEAR REACTORS, ETC.)

**ENGG. MATERIALS
HAVING MUCH SUPERIOR
PROPERTIES**

**ULTRAHIGH STRENGTH , HARDNESS
VERY HIGH TEMPTURE RESISTANCE
DIFFICULT TO MACHINE BY
CONVENVENTIONAL MACHINING
METHODS**

WORK PIECE MATERIAL HARDNESS >> TOOL MATERIAL HARDNESS

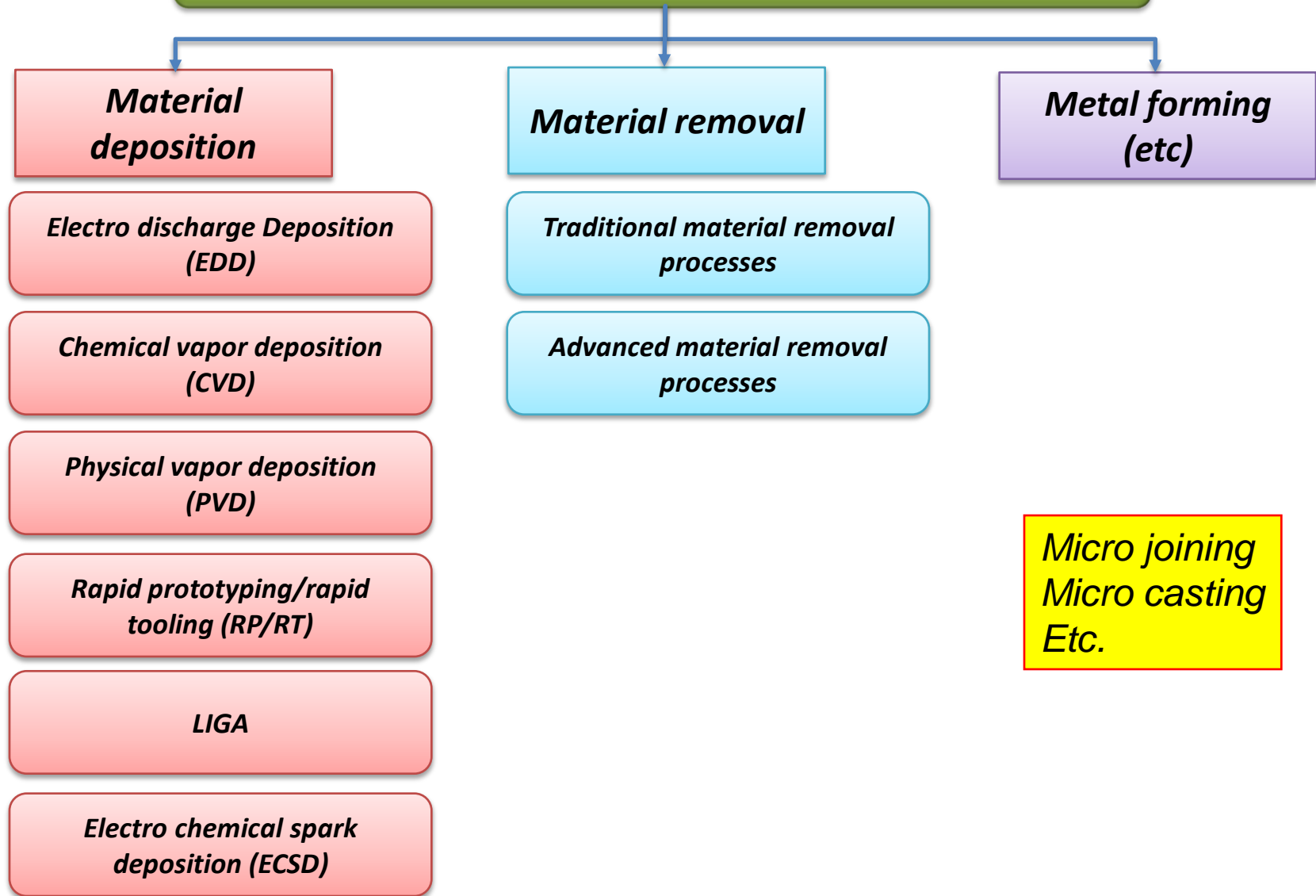
HOW TO SOLVE THE PROBLEM



ADVANCED MICRO MACHINING PROCESSES

WORKPIECE HARDNESS DOES NOT MATTER IN AMMPs

METHODS OF MICRO FABRICATION



WHY DO YOU NEED OF MMPs?

Why miniaturization?

Minimizing energy and materials use in manufacturing

Reduction of power budget

Faster devices

Increased selectivity and sensitivity

Improved accuracy and reliability

Cost/ performance advantages

Integration with electronics, simplifying systems

Size Comparisons in Micromanufacturing



- *100 micrometers ~ paper thickness, human hair*
- *8 micrometers ~ red blood cell, capillaries*
- *0.5 micrometers ~ visible light, machining tolerance*
- *0.07 micrometers ~ year 2010 IC production design rules*
- *0.0003 micrometers ~ atomic spacing in solids*

MICRO-PRODUCTS

NOWADAYS , FOCUS IS ON MINIATURIZATION THROUGH DEVELOPMENT OF NOVEL PRODUCTION CONCEPTS (SPECIALLY MICRO & NANO) FOR THE PROCESSING OF NON-CERAMIC MATERIALS.

MICROFABRICATION DEALS WITH ALL KIND OF MANUFACTURING PROCESSES BUT AT MICRO & NANO LEVEL.

THE REPLICATION OF MICROPARTS THROUGH MOLDING IS ONE OF THE PREFERRED ROUTES FOR MICROMANUFACTURE BECAUSE OF ITS MASS-PRODUCTION CAPABILITY AND RELATIVELY LOW COST.

HOWEVER IN THIS COURSE I WILL MAINLY CONCENTRATE ON MICRO ATTRITIOUS PROCESSES : “MICROMACHINING PROCESSES”

Material Removal Processes

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graph TD; A[Material Removal Processes] --> B[Micro/nano machining]; A --> C[Micro/nano finishing]; B --> D[Traditional machining processes]; B --> E[Advanced machining processes]; C --> F[Traditional finishing processes]; C --> G[Advanced finishing processes];
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Micro/nano machining

Traditional machining processes

Advanced machining processes

Micro/nano finishing

Traditional finishing processes

Advanced finishing processes

Micro / nano finishing

traditional

Grinding

Lapping

Honing

Advanced

AFM

MAF

MRF

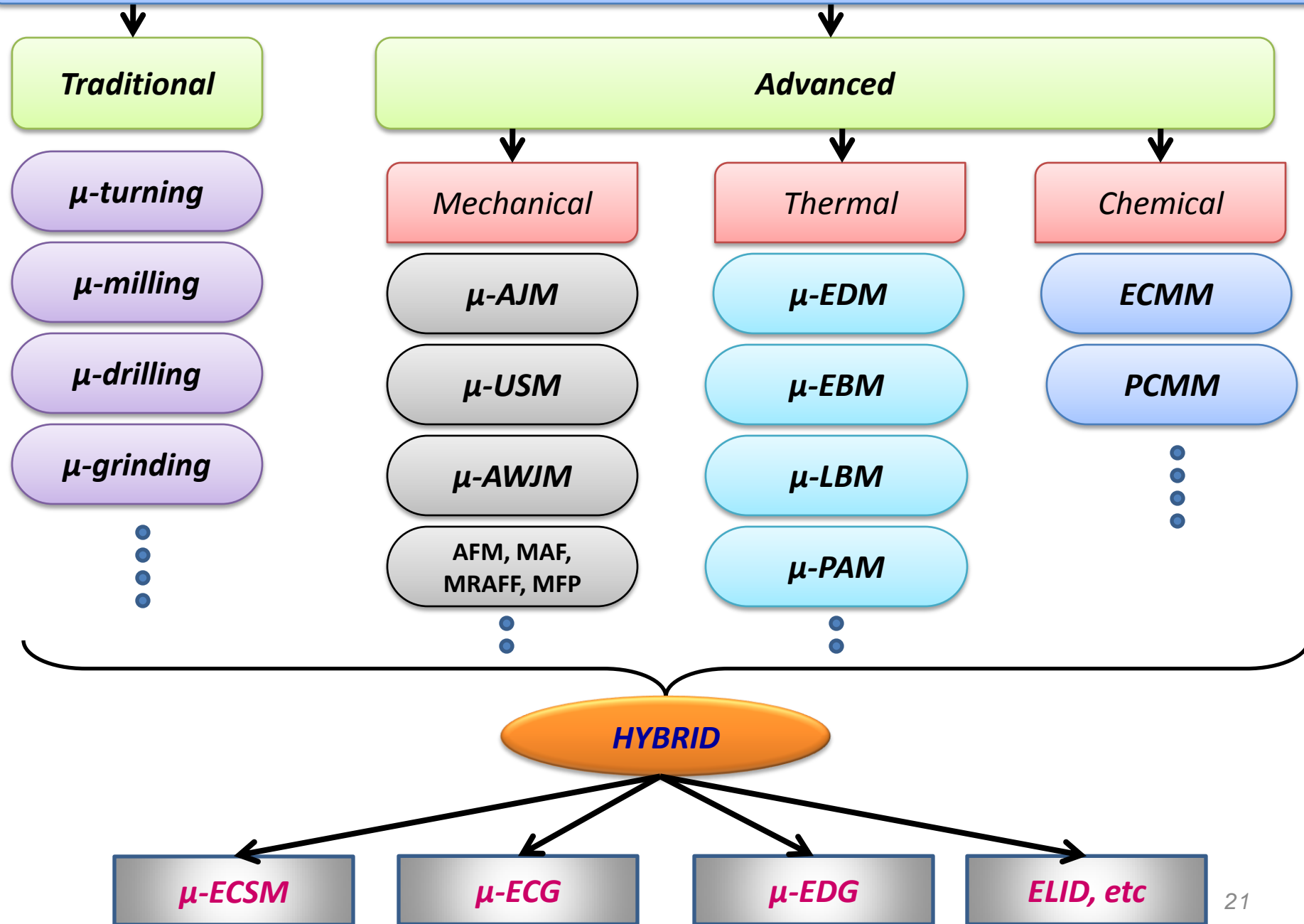
CMP

MRAFF

ELID

MFP

CLASSIFICATION Micromachining Methods BASED ON THE KIND OF ENERGY USED : MACHANICAL, THERMOELECTRIC, ELECTROCHEMICAL & CHEMICAL, BIOCHEMICAL



BASED ON THE PROPERTIES OF WORK MATERIAL TO BE MACHINED



- APPLICABLE ONLY FOR **ELECTRICALLY CONDUCTING MATERIALS** : ECM, EDM, EBM.
- APPLICABLE FOR **BOTH ELECTRICALLY CONDUCTING & NON - CONDUCTING MATERIALS**: USM , AJM, LBM, ETC.
- APPLICABLE FOR **NON – MAGNETIC MATERIALS** : MAF, MRF, ETC.
- **THERMAL CONDUCTIVITY, REFLECTIVITY, ETC.** ALSO PLAY AN IMPORTANT ROLE IN SOME CASES: LBM

EXAMPLES: WHY WE NEED MICROMACHINING / MICROMANUFACTURING?

MICROMACHINING

MICRO



MACHINING

Removal of material at micron level

- **Macro** components but material removal is at micro / nano level
- **Micro / nano** components and material removal is at micro / nano level (Ex. MEMS, NEMS)



Size: 2mm×2mm

Unfortunately, the present day notion is

*Machining of highly miniature components with miniature features. **Literally it is NOT correct***

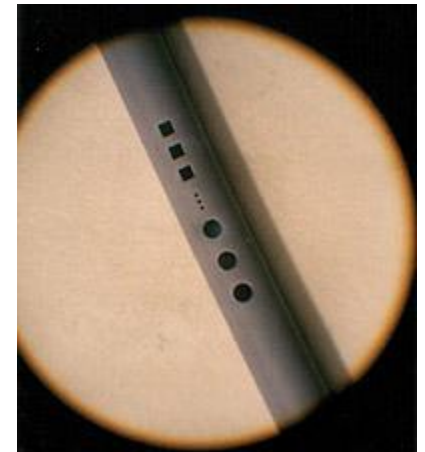
MORE CORRECT DEFINITION IS material removal is micro/nano level WITH NO CONSTRAINT ON THE SIZE OF THE COMPONENT

SOME MICROMACHINED PARTS



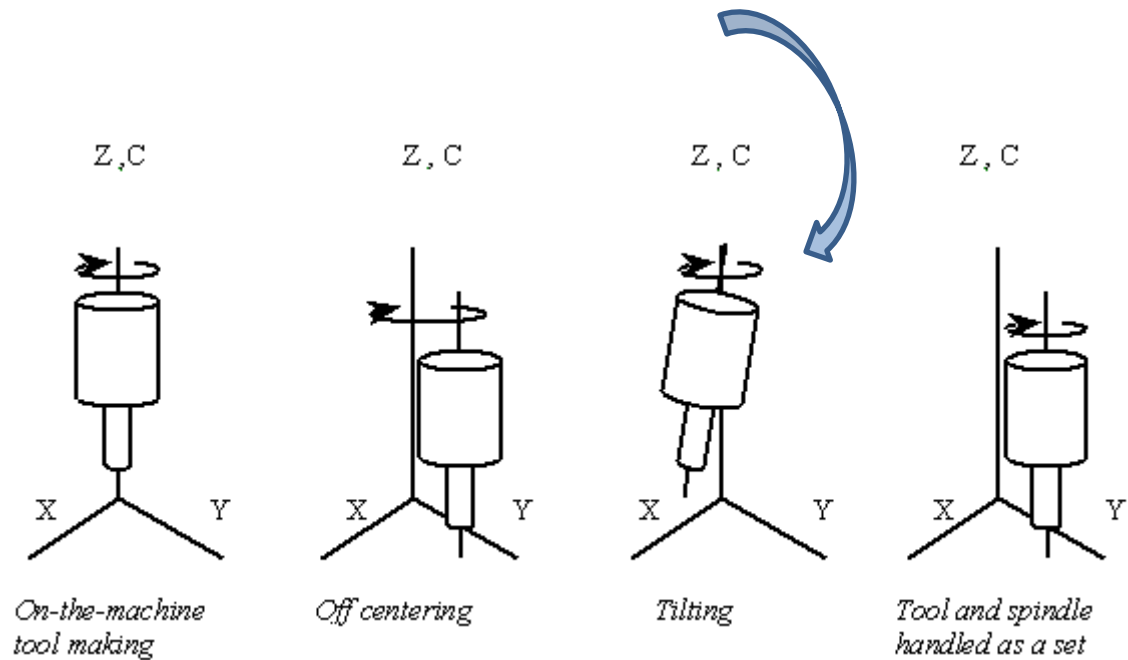
***LASER-CUT STENTLIKE PATTERN
IN MINIATURE STAINLESS- STEEL
TUBE WITH 1.25-mm OD.***

***LASER-DRILLED HOLE (DIA.
15 μ m) PATTERN IN
POLYURETHANE TUBE***



PROBLEMS IN MICROMACHINING

- MECHANICAL DEFORMATION
- THERMAL DEFORMATION
- SURFACE INTEGRITY
- GAP BETWEEN TOOL AND WORK PIECE
- COORDINATE SHIFT IN TOOL HANDLING



ENGINEERING MATERIALS

METALS AND ALLOYS **PLASTICS AND COMPOSITES** CERAMICS

- GETTING MORE POPULARITY
- DEFINITE ADVANTAGES OVER OTHERS

HOW TO
MICROMACHINE
THEM
?

SOLUTION

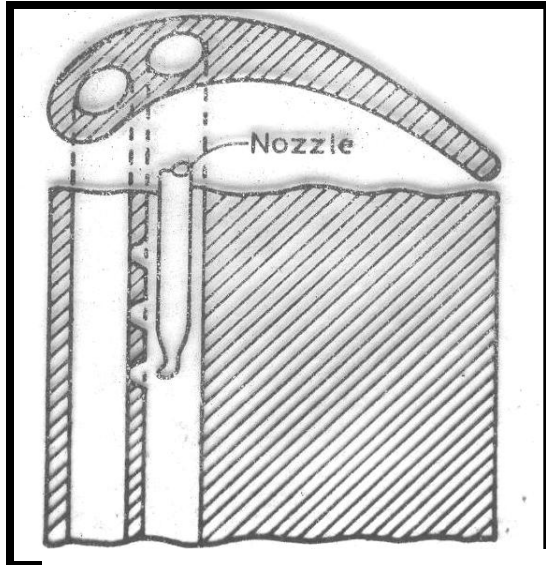
ADVANCED MACHINING PROCESSES

**WHY DO YOU
NEED ADVANCED
MICRO
MACHINING
PROCESSES ?**

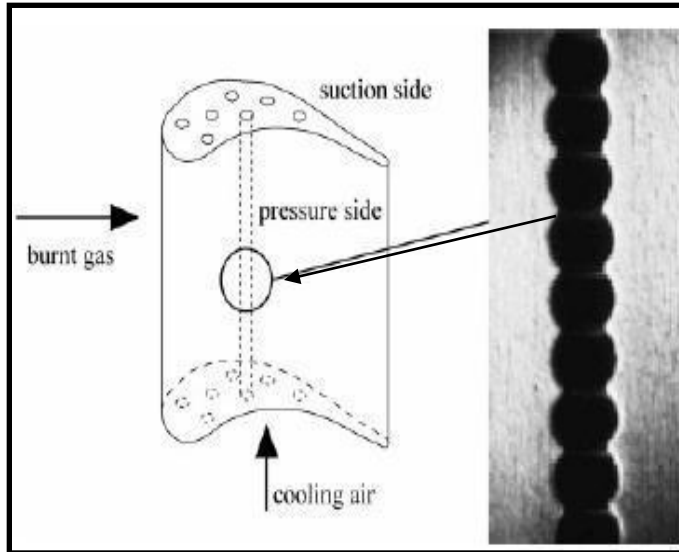
some examples

MICRO MACHINING OF COMPLEX SHAPED WORKPIECES?

ELECTROCHEMICAL MACHINING



HOLE NORMAL TO THE WALL



Turbine Blade with cooling Holes

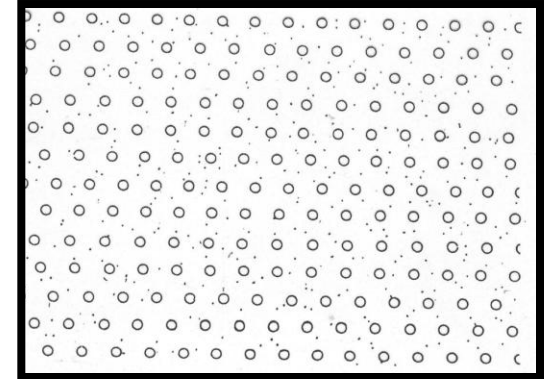
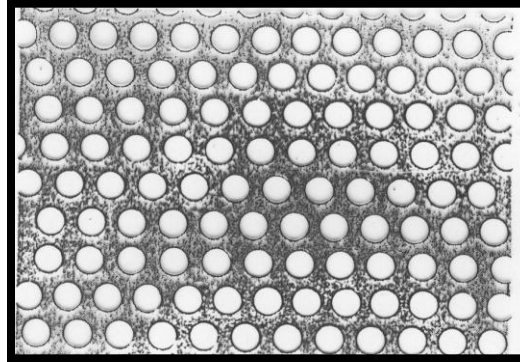
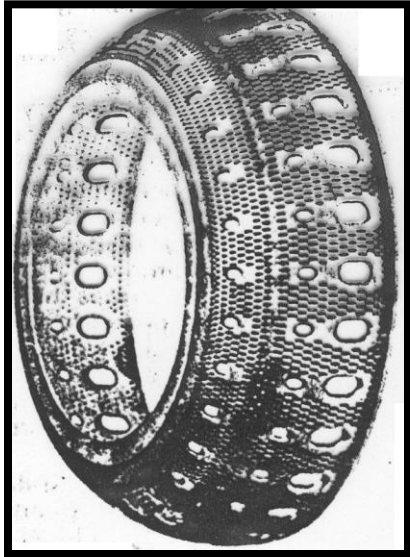
EXPERIMENTAL PARAMETERS	EXPERIMENTAL PROFILE	COMPARISON WITH THEORETICAL PROFILE	PHOTOGRAPH OF MACHINED PROFILED HOLE
Experiment No:3 Voltage: 10.5V Feed rate, f_1 : 0.7 mm/min Feed rate, f_2 : 0.16 mm/min			

PATTERN OF HOLES DRILLED BY EBM

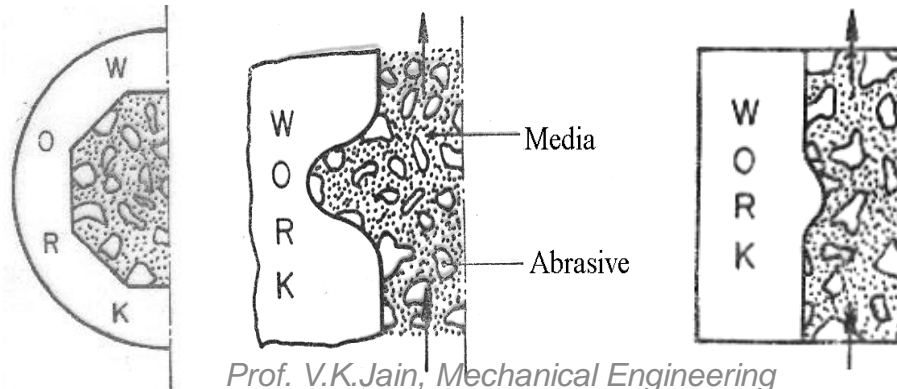
**PART OF A HELICOPTER
TURBINE “ HOLES DRILLED
BY EBM”**

HOLE=0.09 mm ϕ HOLES DENSITY = 4000/cm²
WORKPIECE- S.S.;
THICK = 0.2 MM; TIME = 10 μ S/HOLE

HOLE ϕ = 0.006 mm (6 μ m);
HOLES DENSITY = 200,000 / cm² ;
THICKNESS = 0.12 mm; TIME= 2 μ s / HOLE



AFF MEDIA ACTS AS A SELF-DEFORMABLE STONE

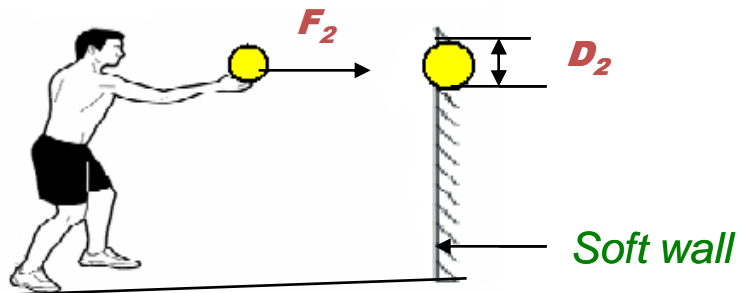
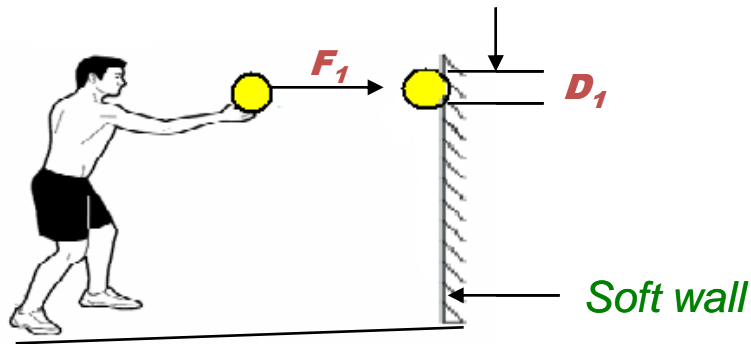


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WORKING PRINCIPLE OF SOME MMPs

- *Abrasive jet micromachining (AJMM)*
- *Abrasive water jet micromachining (AWJMM)*
- *Water jet micromachining (WJMM)*
- *Ultrasonic micromachining (USMM)*

How Abrasive JET Machining (AJM) Works?

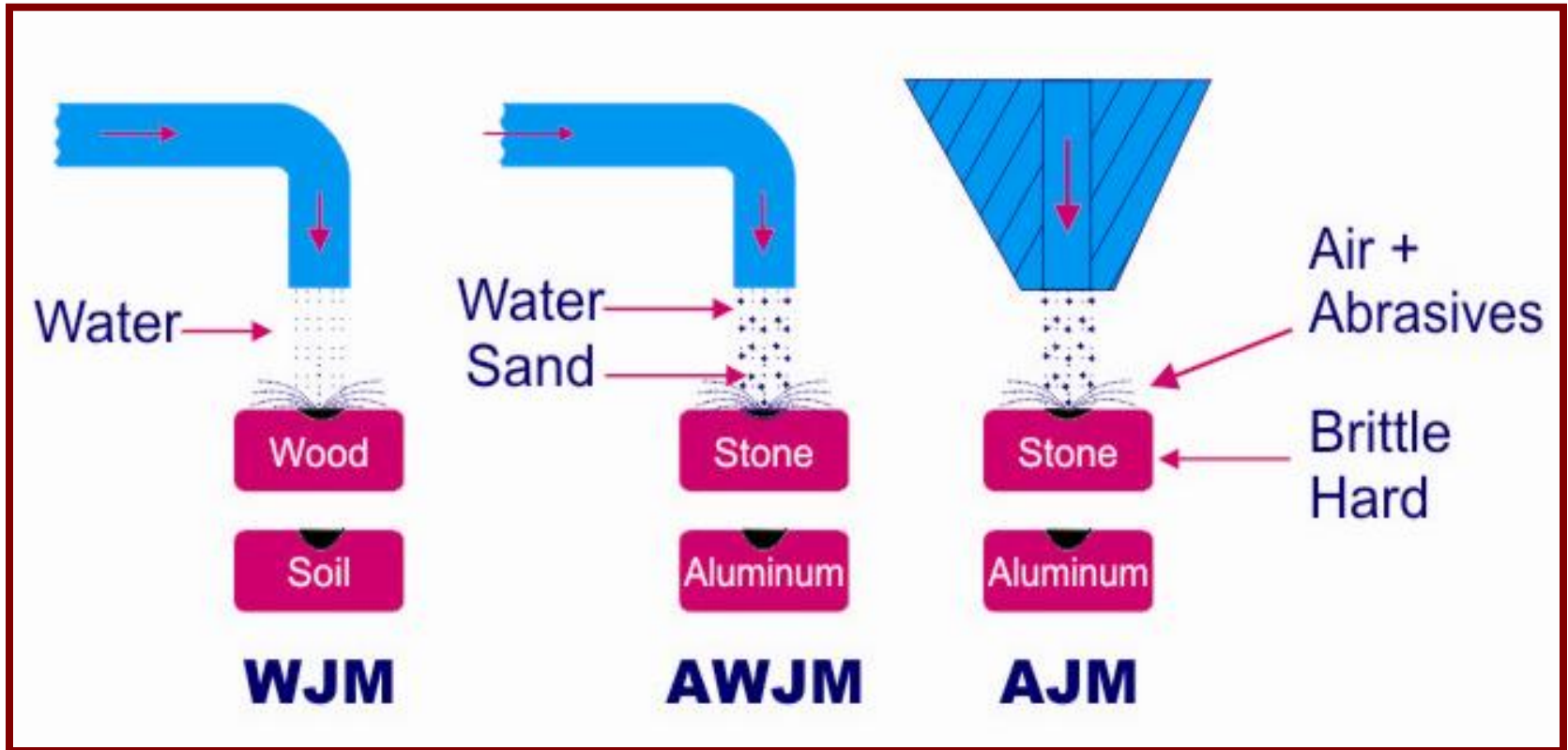


$$F_2 > F_1$$

$$D_2 > D_1$$

- An young boy hits a ball twice on the wall with F_1 & F_2 .
- The ball makes a crater of size D_1 & D_2 such that $D_2 > D_1$ when $F_2 > F_1$.
- D_2 & D_1 size = ϕ (Kinetic energy of the ball when hitting the wall).
= Force (or velocity of the ball with which it hits the wall,
and mass of the ball)
- Abrasive Jet Machining (AJM) works on the same principle.

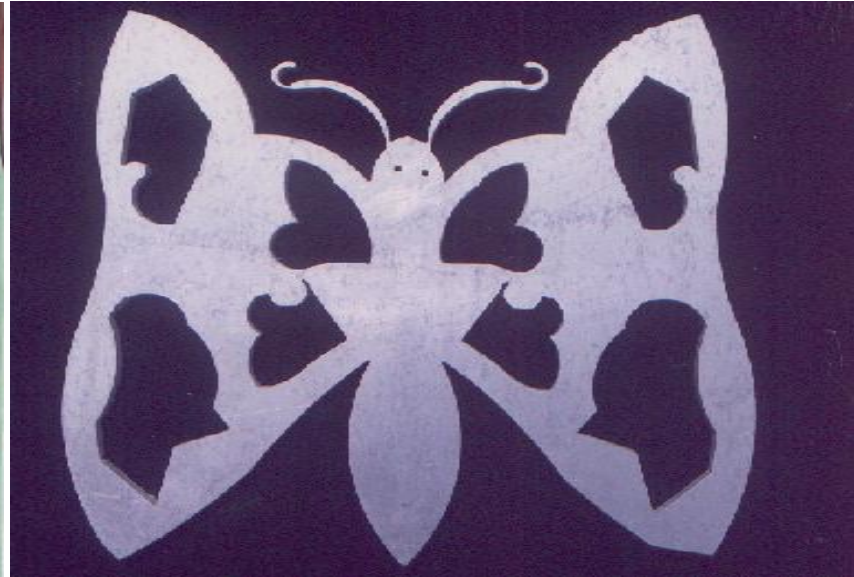
WATER JET MACHINING (WJM), ABRASIVE WATER JET MACHINING (AWJM), AIR JET MACHINING (AJM)



APPLICATIONS OF ABRASIVE WATER JET CUTTING (AWJC)



Granite cutting



COURTESY : IITM CHENNAI

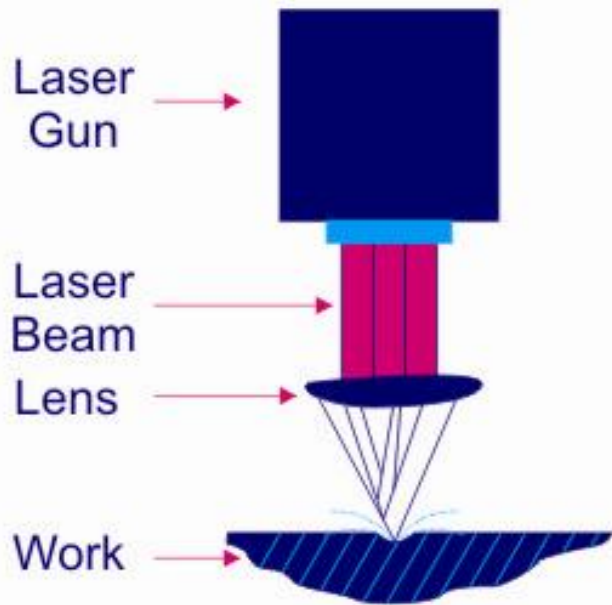
PRINCIPLE OF MECHANICAL ADVANCED MICROMACHINING

- *Fine abrasive particles with high kinetic energy (KE) hit the workpiece at an angle and remove the material in the form of micro/nano-chips.*
- *If the KE of the abrasive particle is high enough, then it will remove the material by **shear deformation in case of ductile workpiece material** and by **brittle fracture if work piece material is brittle**.*

APPLICATIONS

- Holes up to 66 μm deep can be drilled without employing special techniques.
- Micro burrs are clearly visible.
- This process is also useful for producing micro cavity.

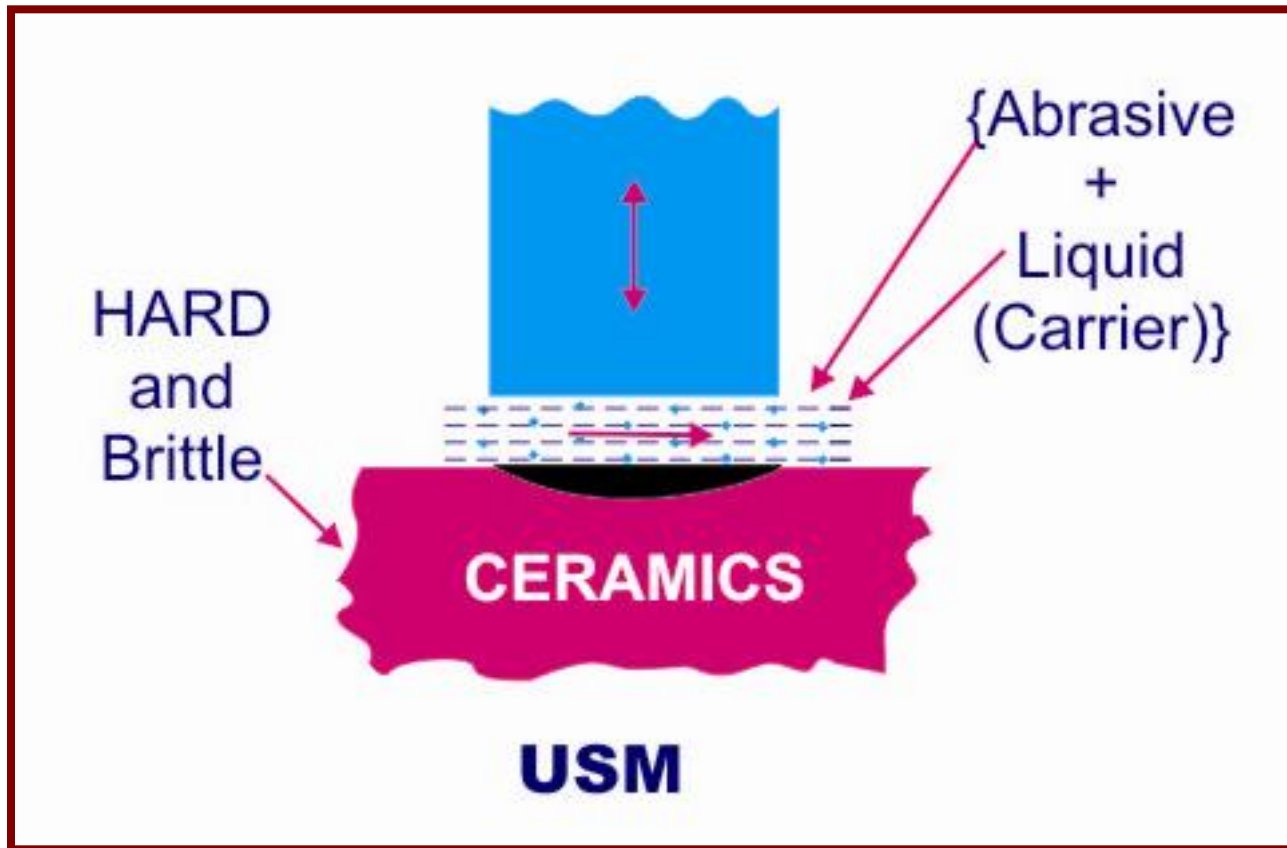
LASER BEAM MACHINING (LBM)



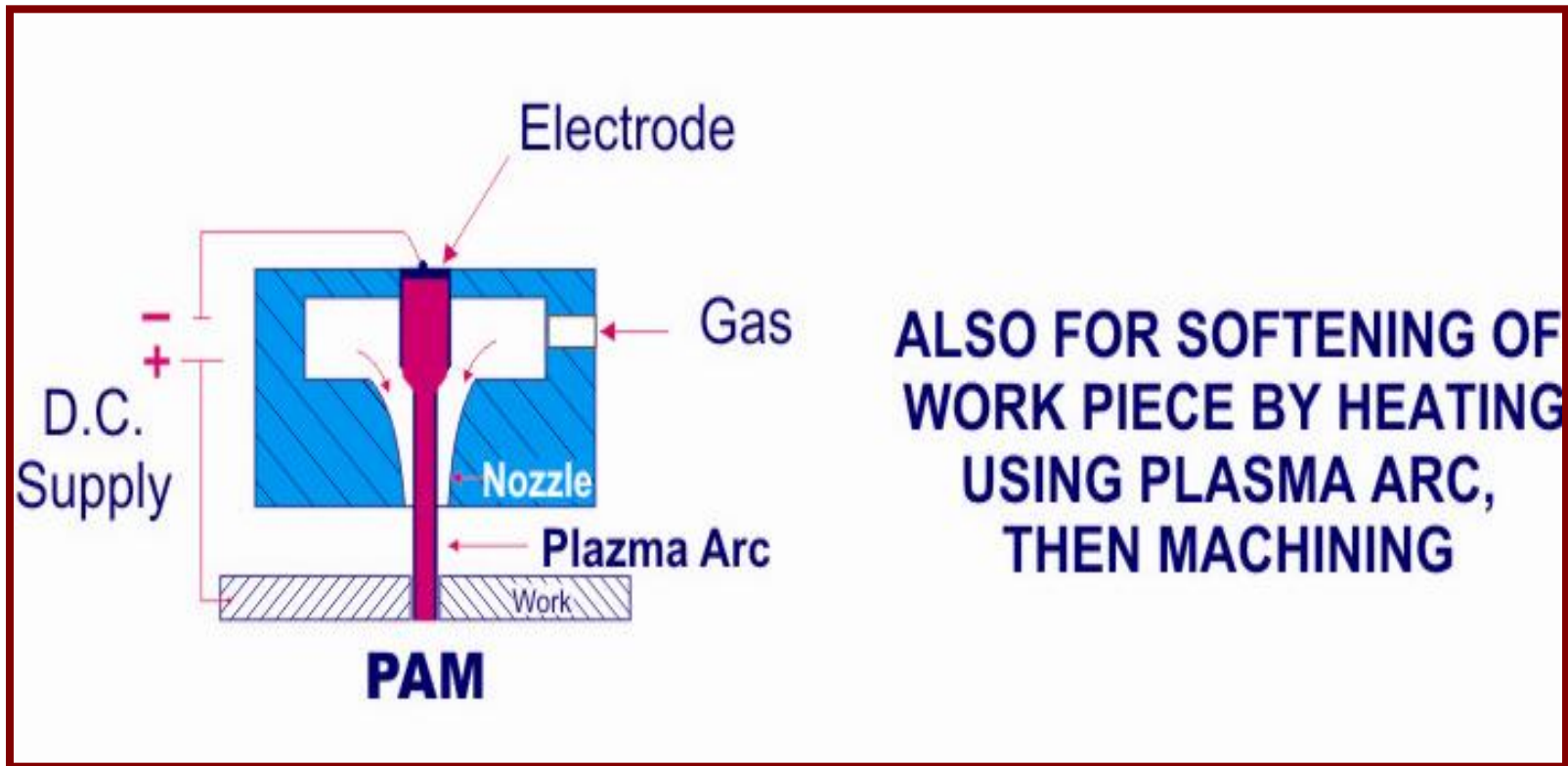
LBM

- Mechanism of material removal.
↓
Melting & vaporization
- For Difficult to machine materials
High thermal conductivity.
↓
High Reflectivity
↓
Al, Cu
- Very low machining efficiency $1 \leq \%$

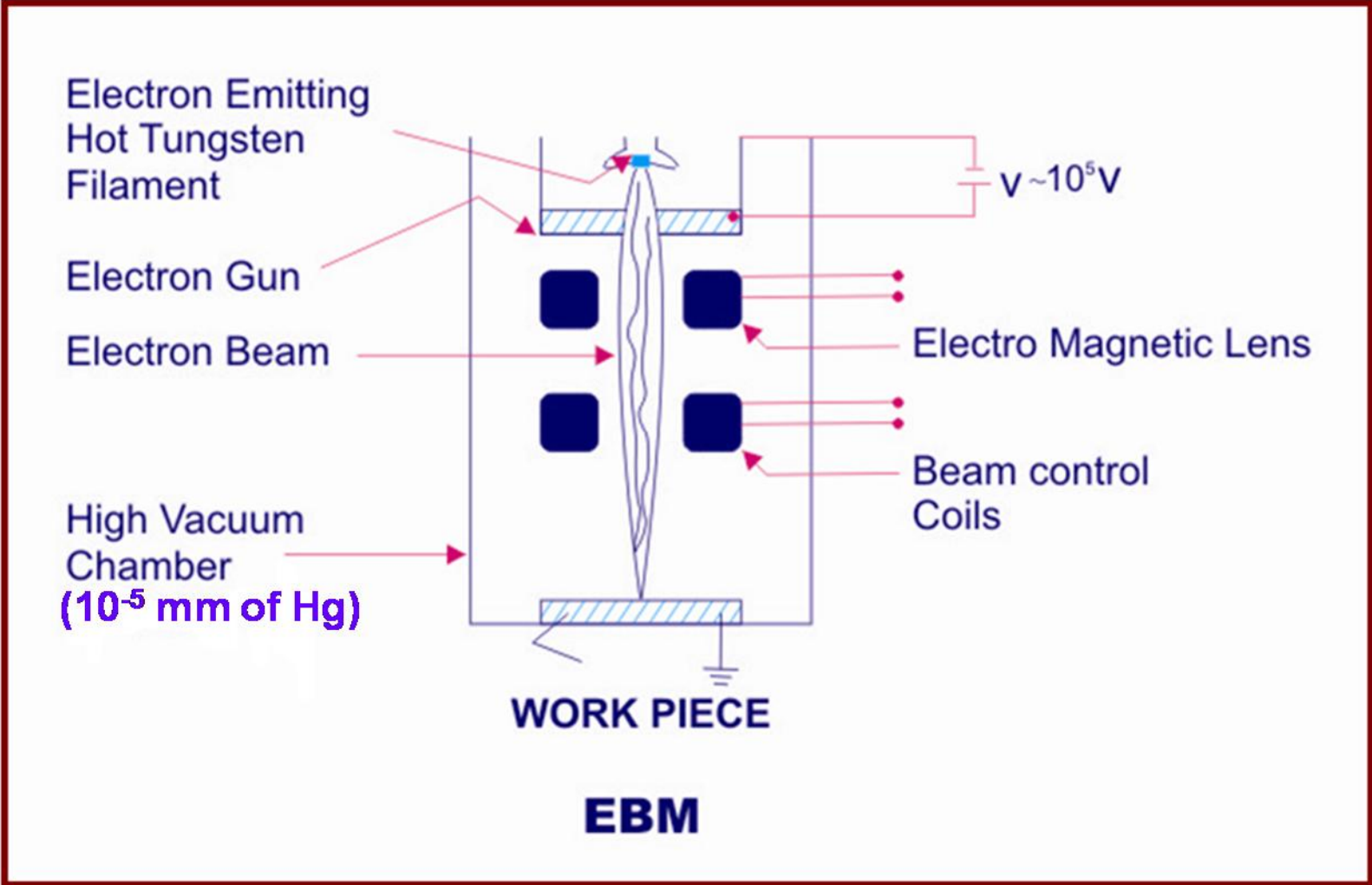
ULTRASONIC MACHINING



LASER BEAM MACHINING (LBM)



ELECTRON BEAM MICROMACHINING



FOCUSSED ION BEAM MACHNING

- ◆ SPUTTERING OFF: KNOCKING OUT ATOMS FROM THE WORK-PIECE SURFACE BY THE KINETIC MOMENTUM TRANSFER FROM INCIDENT ION TO THE TARGET ATOMS
- ◆ REMOVAL OF ATOMS WILL OCCUR WHEN THE ACTUAL ENERGY TRANSFERRED EXCEEDS THE USUAL BINDING ENERGY.

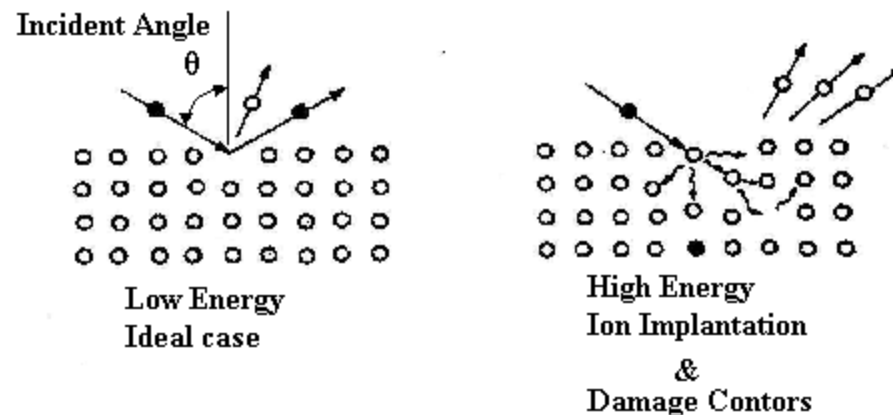
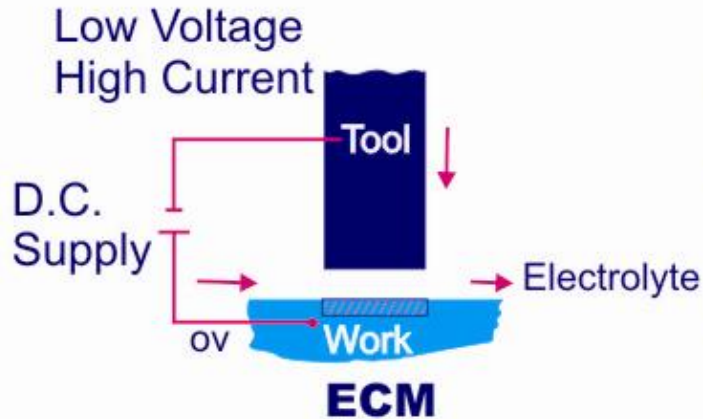


FIG. SCHEMATIC ILLUSTRATION

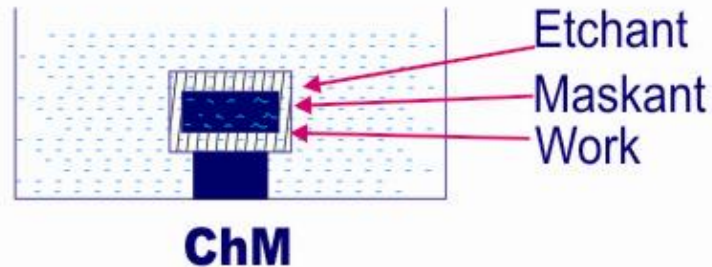
- ◆ AT SUFFICIENTLY HIGH ENERGY, THE CASCADING EVENTS WILL PENETRATE MORE DEEPLY INTO THE SOLID, SEVERAL ATOMS OR MOLECULES WILL BE EJECTED OUT AND THE BOMBARDING ION WILL BECOME IMPLANTED DEEP WITHIN THE MATERIAL.

ELECTROCHEMICAL MACHINING



- Faraday's Laws of Electrolysis
- Electrically Conductive Work only
- Replica of Tool

Chemical Machining



WORKING PRINCIPLE OF NANO FINISHING TECHNIQUES

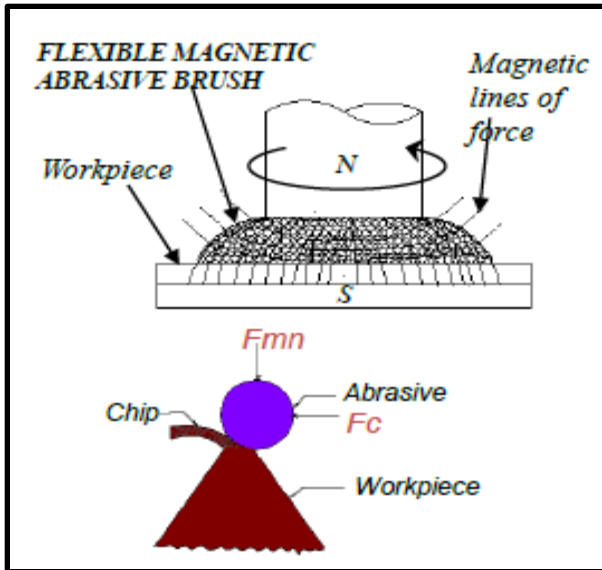
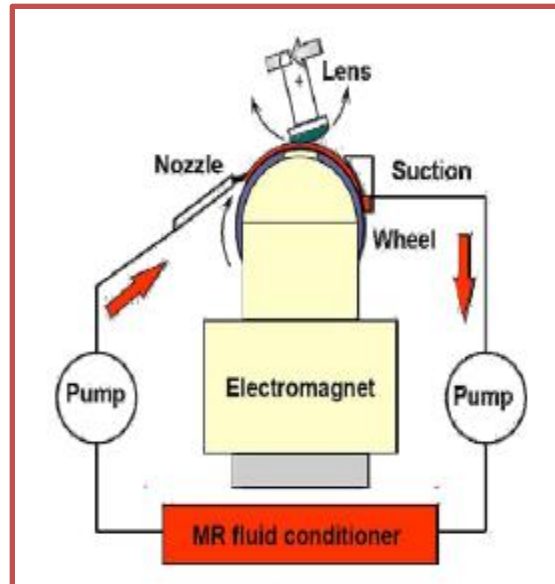
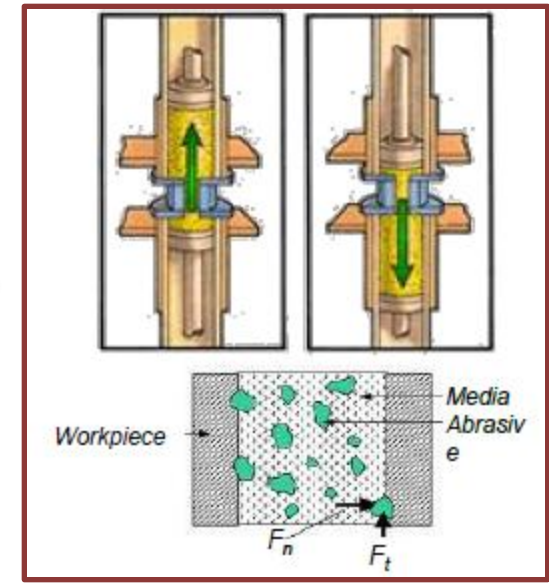


Fig: Magnetic Abrasive finishing (MAF)
 Ref: MAF (Kremen,1994)



MRF

+



AFF

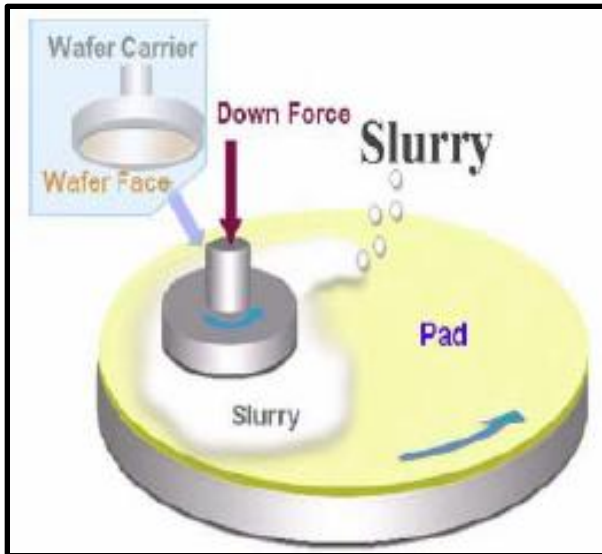
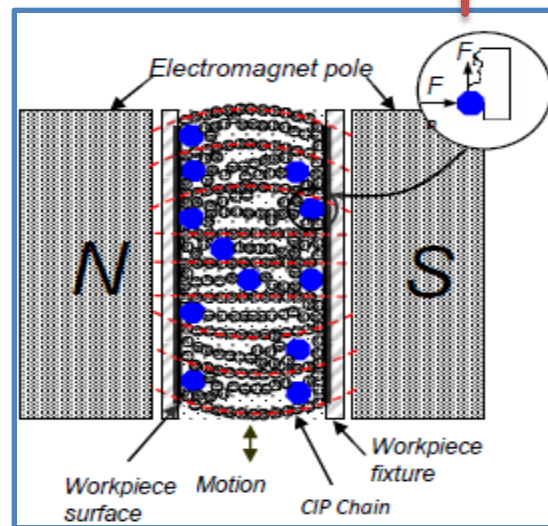
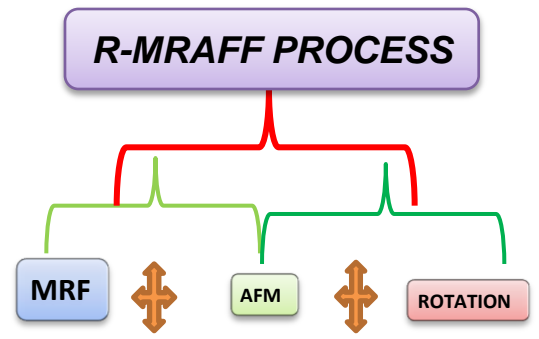


Fig: Chemo mechanical Polishing (CMP)
 Ref: T.H. Tsai et al. (2003)

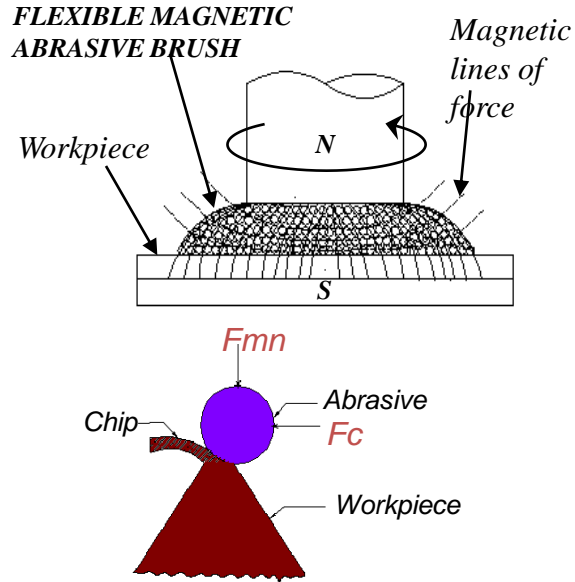


MRAFF

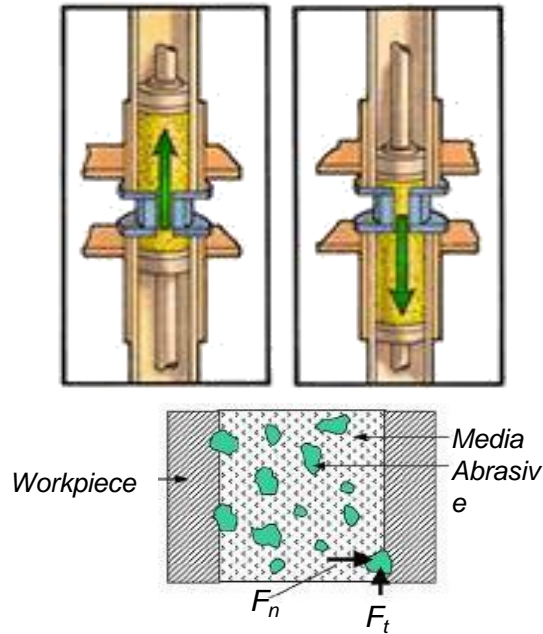
Ref: MRAFF (Jha and Jain, 2004)



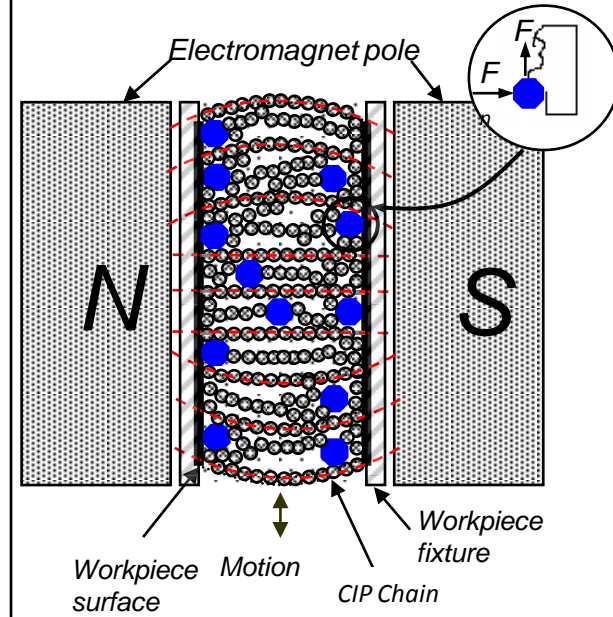
MAF



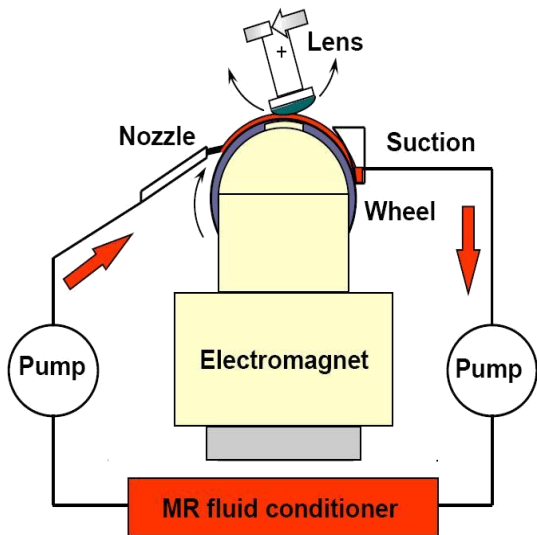
AFM



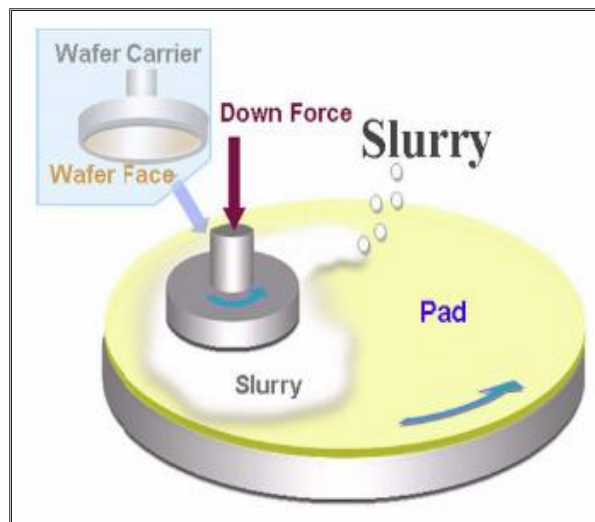
MRAFF



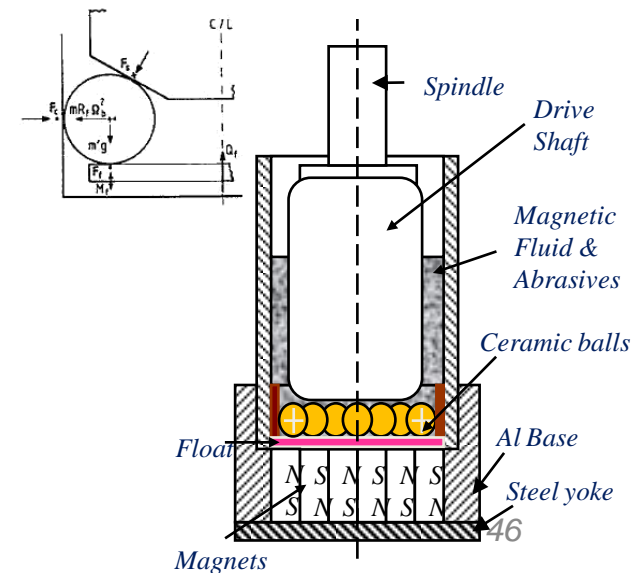
MRF



CMP



MFP



THEMAL ADVANCED MICROMACHINING PROCESSES

- **Electro discharge micromachining (EDMM)**
- *Electro beam micromachining (EBMM)*
- **Laser beam micromachining (LBMM)**
- *Plasma arc micromachining (PAMM)*

PRINCIPLE OF THERMAL ADVANCED MICROMACHINING PROCESSES

- *Localized intense heat is produced which increases temperature of the workpiece in a narrow zone (i.e. Beam diameter), equal to its melting or vaporization temperature*
- *Which leads to removal of material at micro/ nano level in the form of debris (irregular shaped particles or spherical globules).*

**Note: In case of IBM. An ion hits an atom at the top surface of the workpiece, and removes the material atom by atom or in the groups of atoms. There is no thermal damage to the workpiece in IBM*

APPLICATION

- Some of the products include devices such as computer hard disc drive heads, inkjet printer heads, sensors, infrared images.
- *Micro electro-mechanical systems required fabrication with $\mu\text{m}/\text{nm}$ tolerance which is possible with these techniques.*
- Reduced hole *diameter*, lower hole pitch and longer head can be manufactured by thermal micromachining processes.
- *Marking and engraving.*

ELECTROCHEMICAL & CHEMICAL ADVANCED MICROMACHINING PROCESSES

- **Electrochemical micromachining (ECMM)**
- ***Chemical micromachining (ChMM)***
- **Photo Chemical micromachining (PCMM)**
- **Electrochemical spark machining (ECSM)**
- **Electrochemical microdeburring (ECMDe)**

PRINCIPLE OF ELECTROCHEMICAL & CHEMICAL MICRO MACHINING PROCESSES

Electrochemical micromachining:

- *Electrochemical metal removal is an alternate wet etching process*
- *The workpiece made an anode and the tool as cathode in an electrolyte cell in which a nontoxic salt solution is used as an electrolyte*
- *Controlled metal removal takes place when the current (smooth D.C. Or Pulse D.C.) flow through the electrolytic cell*

Chemical micromachining:

- *It is an ancient process being used for engraving the metal for making ornaments and other products.*
- *It removes material in a controlled manner by the application of maskant and etchant.*
- *Maskant does not allow etchant to reach & react with work piece to dissolve it.*
- *Etchant dissolves workpiece material by chemical action.*

ADVANCED NANO FINISHING PROCESSES

- *To finish surfaces to nano level, it is required to remove material in the form of atoms or molecules individually or in groups*
- *Some processes such as Elastic Emission Machining (EEM) and Ion Beam Machining (IBM) work directly by removing atoms and molecules from the workpiece surfaces*
- *While other processes based on finishing by abrasives, remove them (atoms and molecules) In clusters*
- *Most of the nano finishing processes are using abrasive particles either suspended in liquid or held by the viscoelastic material, carbonyl iron particles, or by magnetorheological fluid As a carrier*

Micro/Nano Finishing

Traditional

Grinding

Lapping

Honing

Advanced /Non-traditional

AFM

MRF

MAF

MRAFF

CMP

MFP

ELID

CLASSIFICATION OF ADVANCED NANO-FINISHING PROCESSES

- ***Advanced abrasive finishing processes***
 - *Abrasive Flow Machining (AFM)*
- ***Magnetic field assisted advanced finishing processes (AFPs)***
 - *Magnetic Abrasive Finishing (MAF)*
 - *Magnetic Float Polishing (MFP)*
 - *Magnetorheological Finishing (MRF)*
 - *Magnetorheological Abrasive Flow Finishing (MRAFF)*
- ***Magnetorheological fluids based processes***
 - *Rotational Magnetorheological Abrasive Flow Finishing (R-MRAFF)*

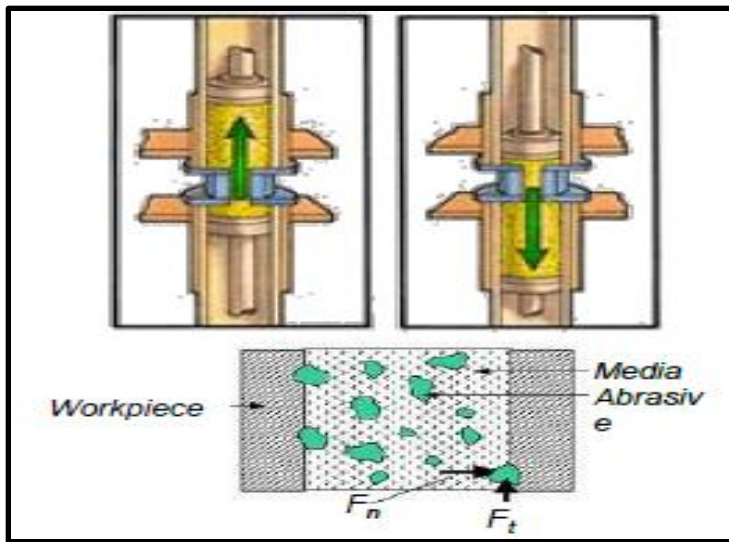


Fig: Abrasive Flow machining (AFM),
 Ref: AFM (Jain and Jain, 1998)

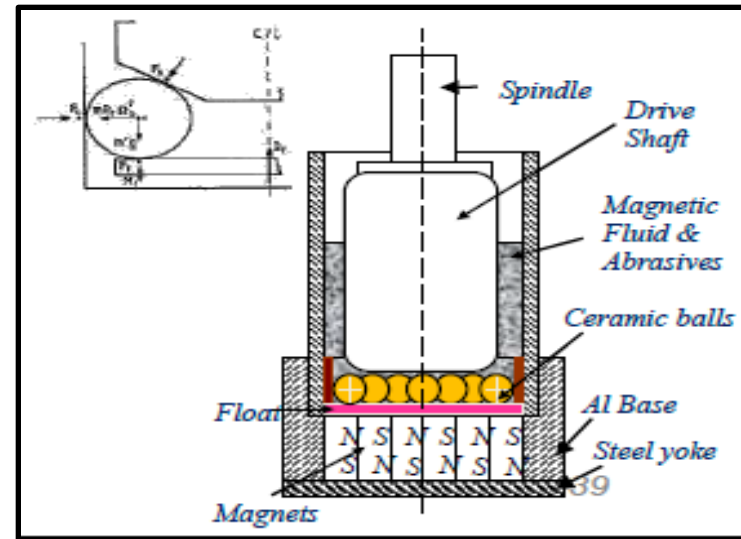
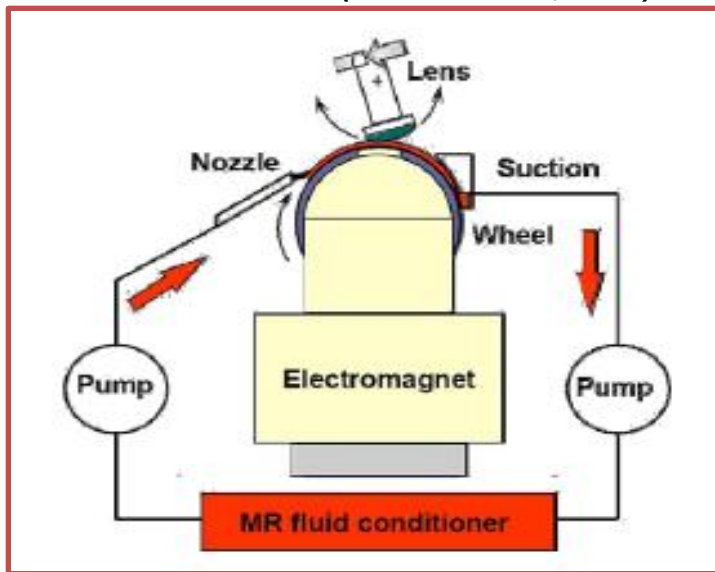
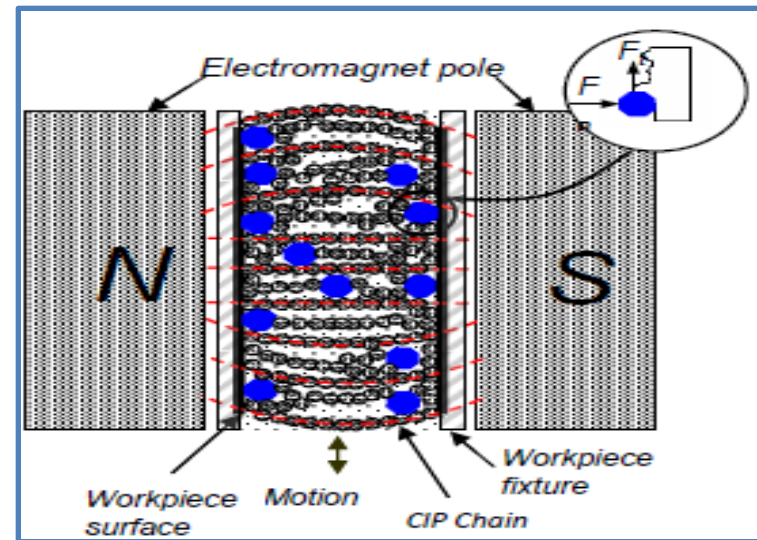


Fig: Magnetic Flot Polishing (MFP)
 Ref: MFP (Komanduri et al., 1997)



Magnetorheological finishing (MRF),
 Ref: MRF Kordonski and Jacobs1 et al., 1996 (QED technologies)



Magnetorheological Abrasive flow finishing (MRAFF)
 Ref: MRAFF (Jha and Jain, 2004)

MAGNETO RHEOLOGICAL ABRASIVE FINISHING (MRF)

- MRF was invented at the Luikov Institute of Heat & Mass Transfer in Minsk, Belarus in the late 1960s by a team led by William Kordonski and after some time they form a company known as **QED technology**.
- MRF is a **deterministic** and magnetic field assisted precision finishing Process.
- MRF uses **MRP fluid** which is **invented by Rabinow** in late 1940s consist of
 - **CIP** (Magnetic),
 - **Abrasive Particle** (Non-magnetic)
 - **carrier liquid** (Oil or water)
 - **additives** (glycerol, grease)
- **MRP fluid** works as **polishing tool**.

Application:

- MRF has been used for finishing a large variety of brittle material ranging from optical glasses to hard crystals.

Limitations:

- **Internal and specially complex surfaces can't be finished.**

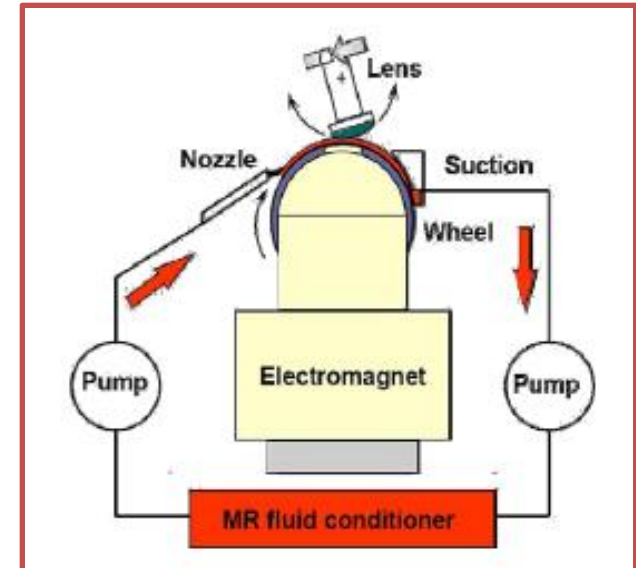
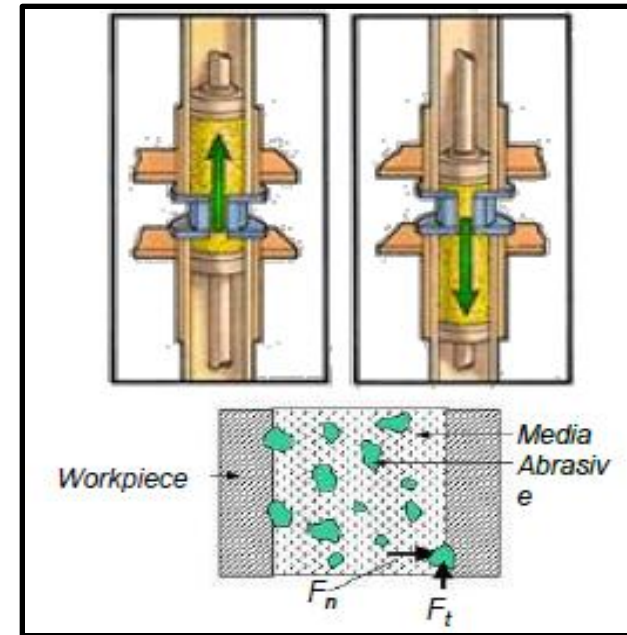


Fig : (a) Vertical wheel MRF machine
Ref: Kordonski and Jacobs1 et al., 1996 (QED technologies)

ABRASIVE FLOW MACHINING (AFM)

- AFM was developed by **Extude Home Corporation USA** in 1960 as a method to **deburr**, **polish** and **radius** difficult to reach surface like intricate geometries and edges by flowing a **abrasive laden viscoelastic medium** over them



Abrasive Flow machining (AFM),
Ref: AFM (Jain and Jain, 1998)

Key Component

Machine

Tooling

Abrasive
Medium

Process Input Parameters

Extrusion Pressure

No. Of Cycle

Grit Composition
& Type

Tolling &
Fixture

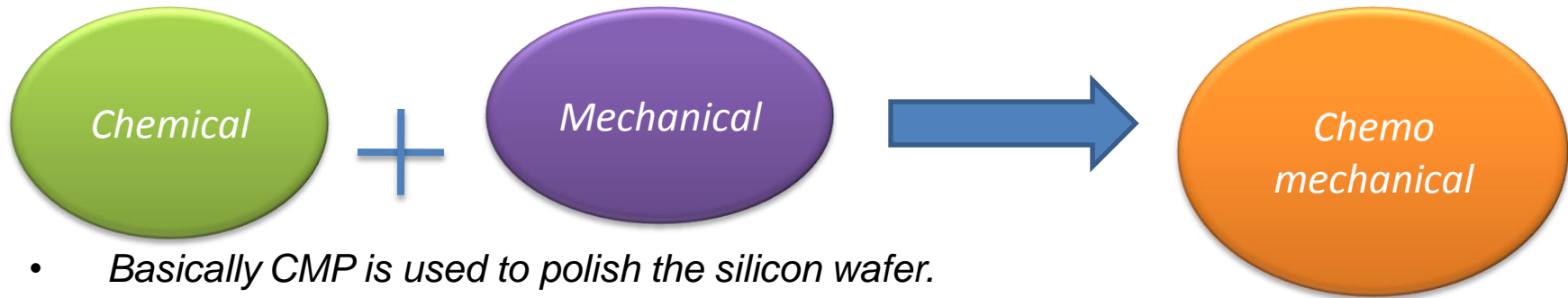
Application:

- In industries such as Aerospace, medical, electronics, Automotive, Precision dies and mould as part Of manufacturing activities.

Limitations:

- **AFM is not deterministic process.**

CHEMO MECHANICAL POLISHING (CMP)



- Basically CMP is used to polish the silicon wafer.
- Wafer-Pad-Slurry interactions

Why CMP:

- Local planarization
- Global planarization

Principle:

- CMP uses both **chemical** and **mechanical** type or material removal mechanism.
- Chemical reaction to **soften material** and then **mechanically polish off this layer**.
- Mechanical removal takes place due to **abrading**.

Limitations:

- This process is used for only **flat surfaces**.
- CMP is not deterministic in nature.
- Endpoint of CMP is a **difficult to control for a desired thickness**.



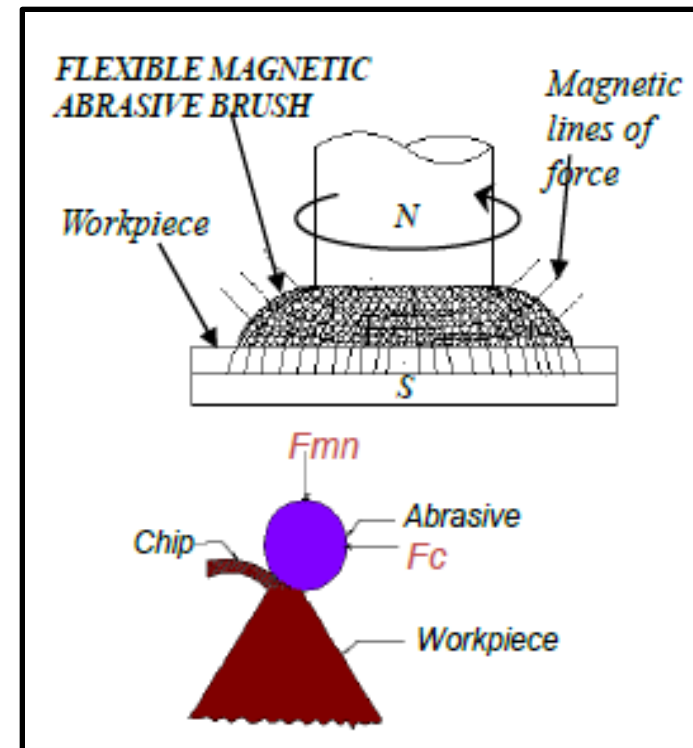
Fig: Chemo mechanical Polishing (CMP)
Ref: T.H. Tsai et al. (2003)

MAGNETIC ABRASIVE FINISHING (MAF)

- In MAF finishing is performed by the application of **magnetic field** across the gap b/w the workpiece surface & the rotating electromagnet pole.
 - The magnetic abrasive particles are attracted with each other magnetically b/w magnetic poles along the lines of magnetic force forming a **flexible magnetic abrasive brush**.
 - MAF was developed to produce efficiently and economically good quality finish on **the internal and external surface of tubes as well as flat** surface made of magnetic or non-magnetic material.
- **8-9 nm surface roughness value (High surface finish)**

Limitations:

- **MAF can not be used for complex geometries.**



Magnetic Abrasive finishing (MAF)

Ref: MAF (Kremen,1994)

MAGNETIC FLOAT POLISHING (MFP)

- Magnetic Float Polishing is a technique based on the **Magnetohydrodynamic behaviour** of the magnetic fluid which in the presence of magnetic field can levitate a non-magnetic float and abrasive particles suspended in it.
- The forces applied by abrasives **are extremely small and controllable**.
- When the magnetic field is applied the ferromagnetic particle in the ferrofluid are **attracted downward to the area of higher magnetic field and upward buoyant force is exerted on all non-magnetic materials to push them to the area of lower magnetic field**.
- The balls are polished by the abrasive particles mainly due to the action of the **magnetic buoyancy force when the spindle rotates**

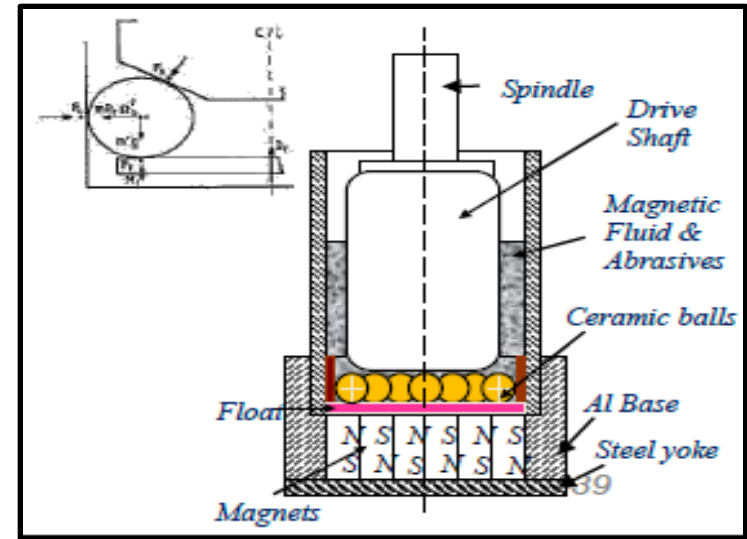
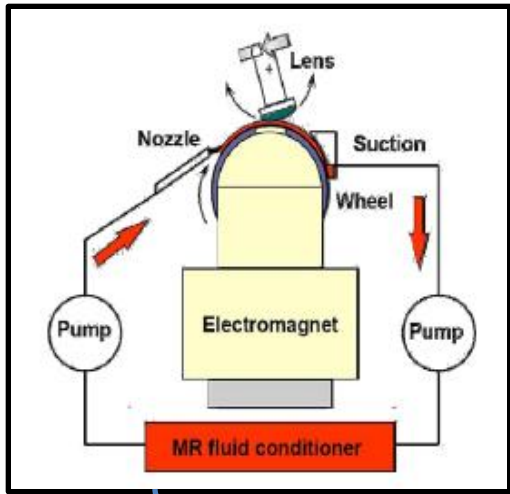


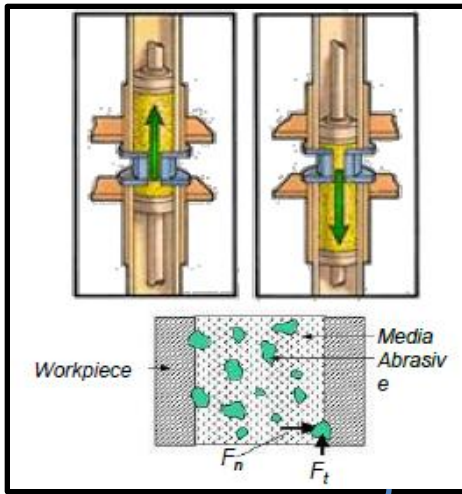
Fig: Magnetic Float Polishing (MFP)
Ref: MFP (Komanduri et al., 1997)

MAGNETORHEOLOGICAL ABRASIVE FLOW FINISHING (MRAFF)

- MRAFF is the **hybrid finishing process** to take the advantage of both the finishing process (**MRF** & **AFF**)
- It is **deterministic process**.
- Any complex geometries can be finished by this process.



MRF



AFF

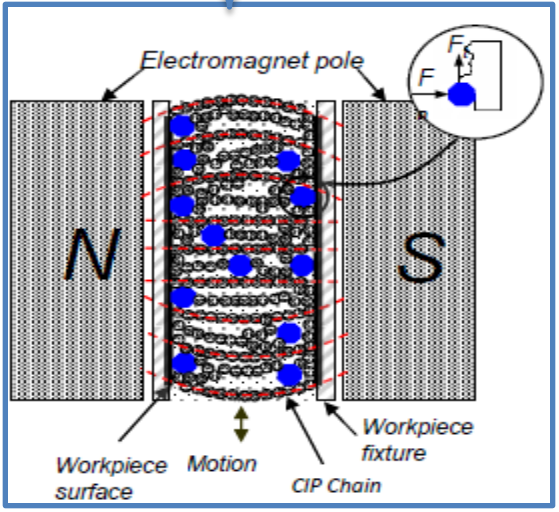
Limitations:

➤ **Non-uniform surface** in case of freeform surface

Why low finishing rate.....?

➤ **Low finishing rate** because interaction between the NMAPs and w/p surface is in straight line sweeping a small area.

• Only a small percentage of NMAPs which are on the periphery of the slug actually participate in the finishing operations.



MRAFF

Ref: MRAFF (Jha and Jain, 2004)

ROTATIONAL - MAGNETORHEOLOGICAL ABRASIVE FLOW FINISHING (R-MRAFF)

How to increase the finishing rate in MRAFF

Solution

- One way to rotate the medium itself and other is to rotate the workpiece.
- Rotation of w/p is difficult in the existing MRAFF setup with the possible chance of leakage of medium.
- Therefore, rotation of the medium has been adopted by rotating the magnetic field and the process is named as (R-MRAFF).

R-MRAFF PROCESS

MRF

AFM

ROTATION

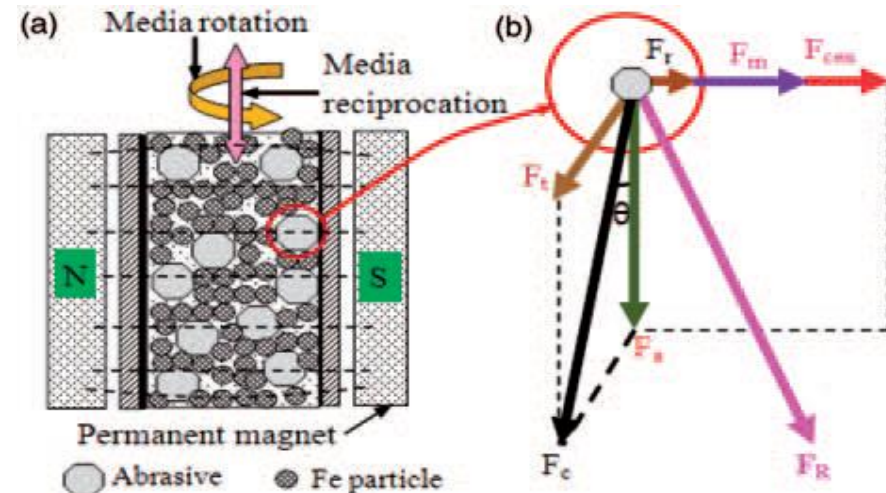


Fig: (a) Schematic of Fe particles chains structure and (b) force components acting on NMAP in R-MRAFF process

Ref: V K Jain, et al. (2012)

- The magnetic iron particles chains structure and force components acting on each NMAP During R-MRAFF process.
- The magnitude of magnetic force (F_m) acting on the individual NMAP is given as follows.

$$F_m = m\mu_o \chi_m H\Delta H$$

Where

- m = Mass of a magnetic (Fe) particle
- χ_m = mass susceptibility of the magnetic particle
- H = magnetic field intensity
- ΔH = Gradient of the magnetic field intensity
- μ_o = Permeability in free space

- Axial force (F_a) and radial force (F_r) act on the NMAP due To the reciprocation of the medium by hydraulic unit.
- Axial force (F_a) is responsible for shearing.
- Radial force (F_r) helps the NMAP in indenting the w/p surface.
- Axial force (F_a) and Radial force (F_r) are proportional to the hydraulic extrusion pressure (P) and medium viscosity ($F_r=kP$) where k is constant.

- The total normal indentation force is the sum of these three forces

$$F_{\text{indentation}} = F_m + F_{\text{cen}} + F_r$$

Where

F_m = Magnetic force

F_{cen} = Centrifugal force

F_r = Radial force

F_t = Tangential cutting force

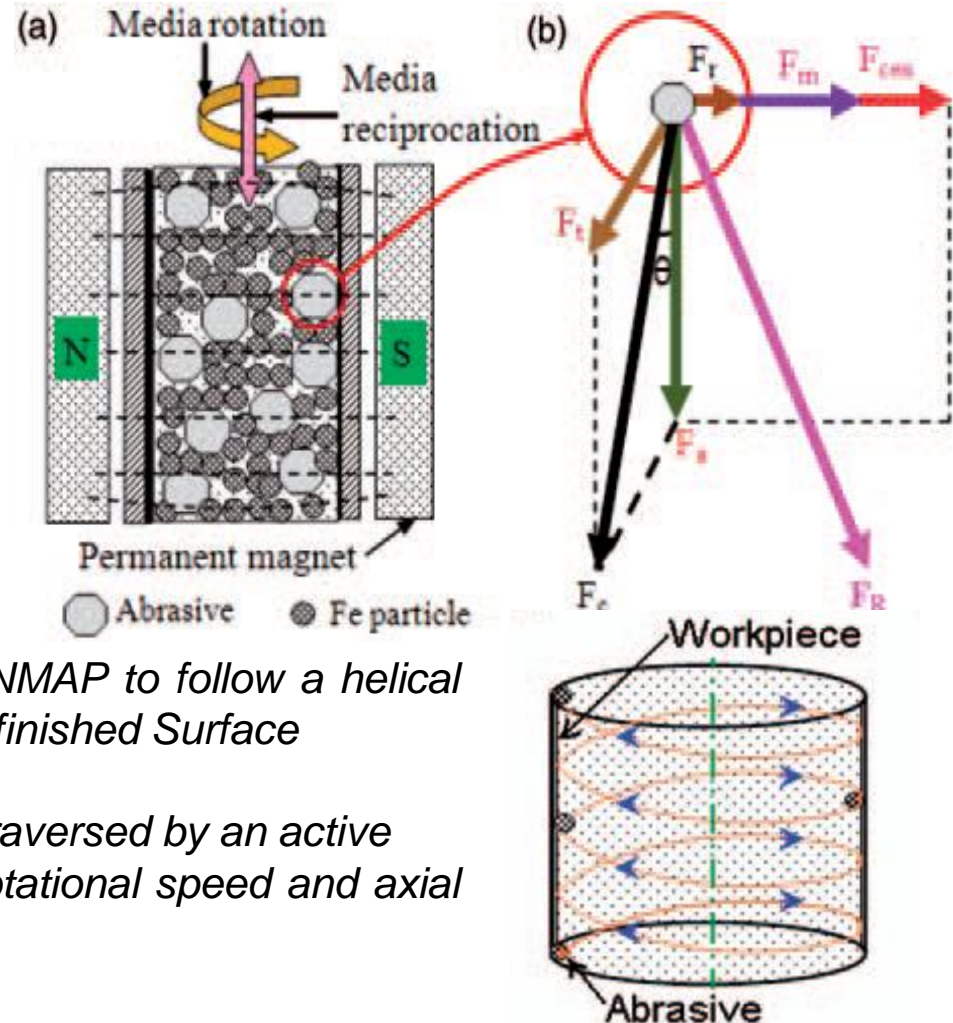
$$F_{\text{cen}} = mr\omega^2$$

$$F_c = F_a + F_t$$

$$F_t = 2m(\omega \times v)$$

- The resultant force F_c makes the active NMAP to follow a helical path. It produces cross-hatch pattern on the finished Surface
- Helix angle and length of the helical path traversed by an active NMAP around the w/p are the function of rotational speed and axial velocity of the medium.

Higher finishing rate comparison to MRAFF.



Ref: V K Jain et al. (2012)



Methods of Micro fabrication

Material deposition

Electro chemical spark deposition

Electro discharge deposition

Chemical vapour deposition

Physical vapour deposition

Rapid prototyping / rapid tooling

LIGA

Material removal

Traditional material removal processes

Advanced material removal processes

Micro machining

Traditional

μ -turning

μ -milling

μ -drilling



Advanced

μ -EDM

μ -ECM

μ -AJM

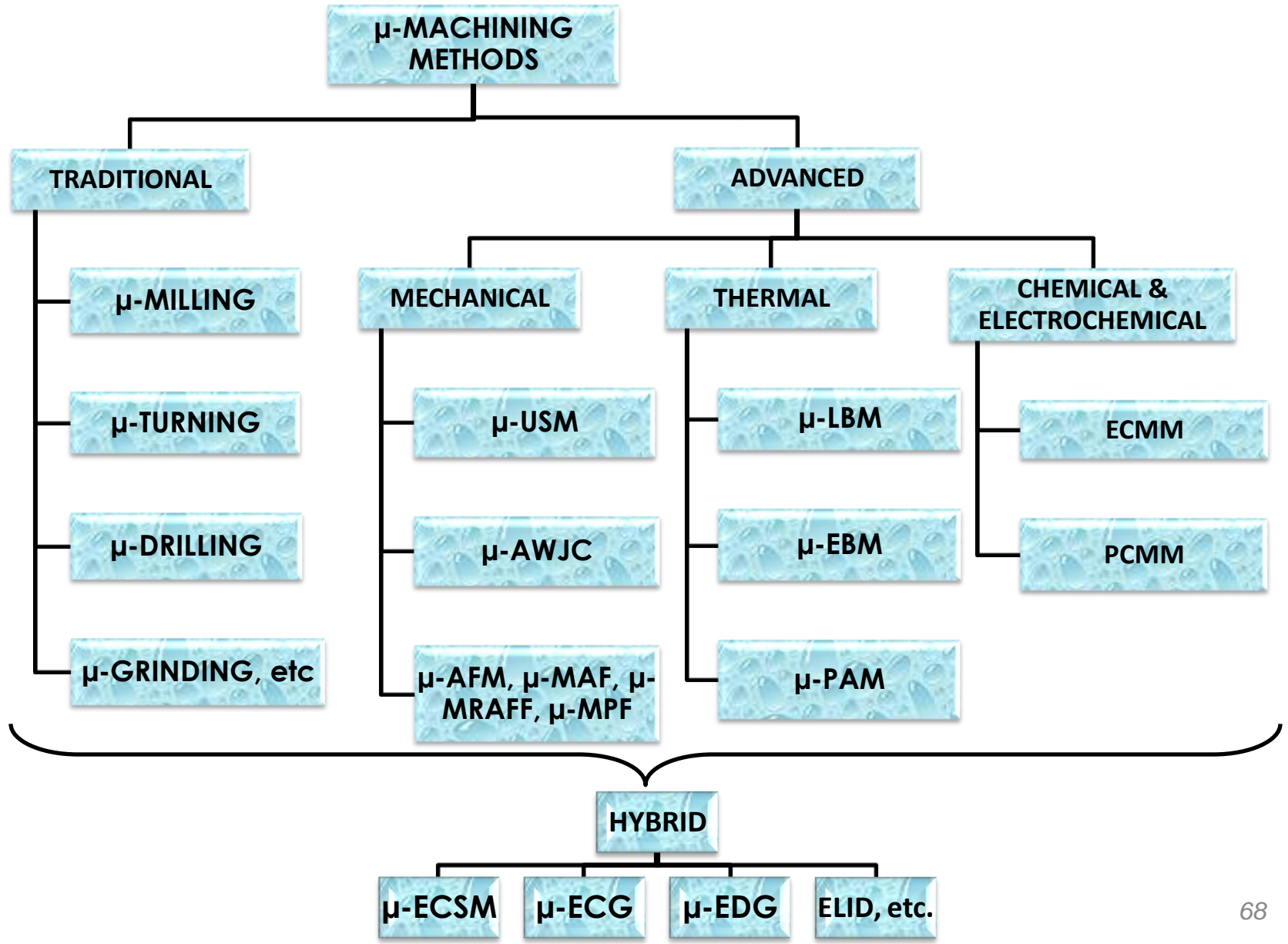
LBM

EBM

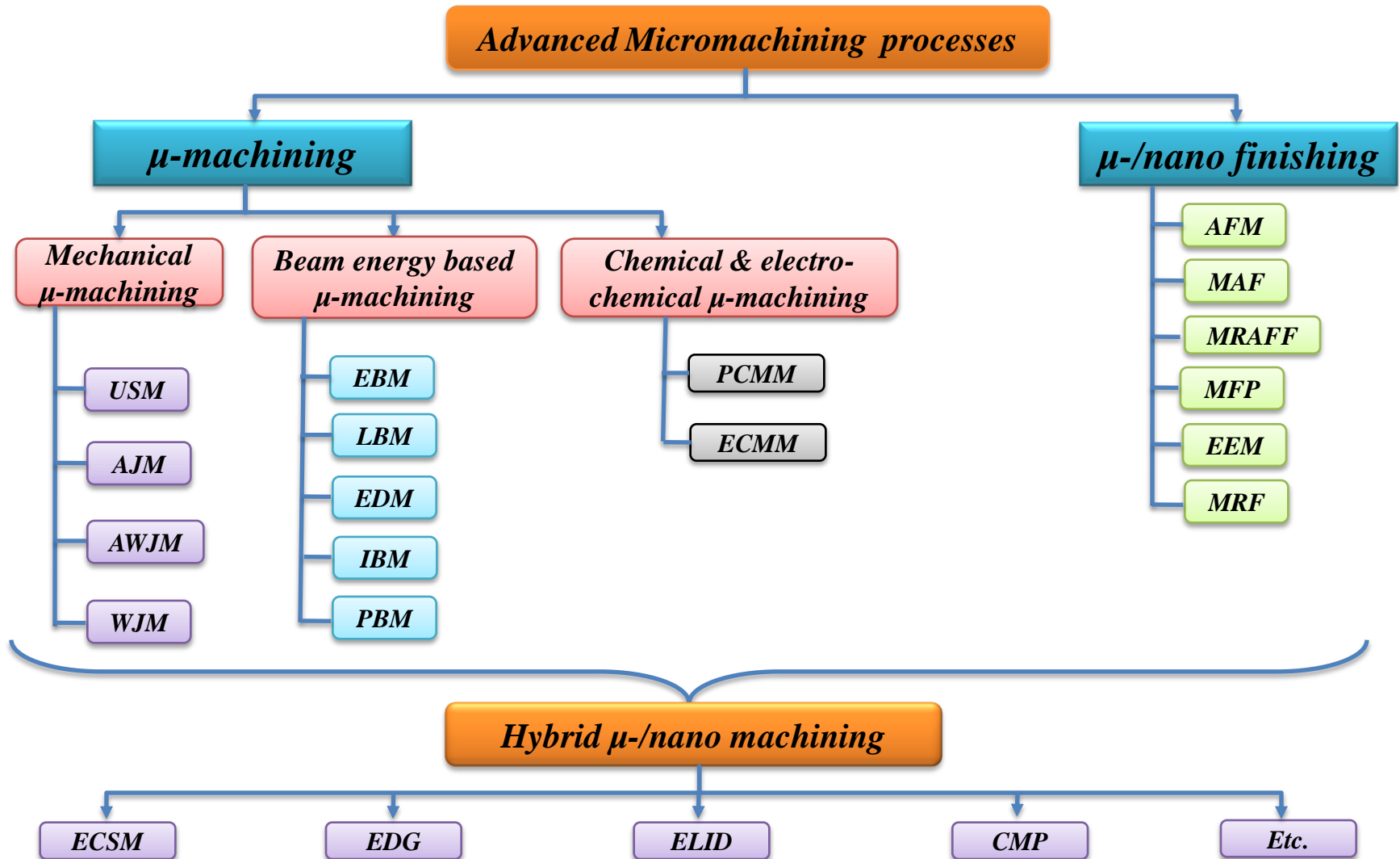
μ -USM



CLASSIFICATION OF MICROMACHINING



CLASSIFICATION OF MICROMACHINING AND NANOFINISHING PROCESSES



PRINCIPLE OF MECHANICAL ADVANCED MICROMACHINING

Fig: Abrasive water jet micromachining

Fig: Water jet micromachining

Fig: Abrasive jet micromachining

Fig: Ultrasonic micromachining